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<p>(54) Title: PROCESS TO REDUCE THE AOX LEVEL OF WET-STRENGTH RESINS BY TREATMENT WITH BASE</p> <p>(57) Abstract</p> <p>Process for reducing the AOX content of wet-strength resins, such as polyaminopolyamide-epi or polyalkylene polyamine-epi resins, by treatment with base, e.g. sodium hydroxide, while maintaining the wet-strength effectiveness of the resin.</p>			

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5 **PROCESS TO REDUCE THE AOX LEVEL OF WET STRENGTH RESINS BY
 TREATMENT WITH BASE**

Background of the Invention

10 **Field of the Invention**

 The present invention relates to the process of reducing the adsorbable organic halogen (AOX) level in wet-strength resins while maintaining or improving their wet-strength effectiveness and more particularly it relates to treating such resins with base.

15 **Description of the Prior Art**

 Commercial polyaminopolyamide-epichlorohydrin resins typically contain 1-10% (dry basis) of the epichlorohydrin (epi) by-products, 1,3-dichloropropanol (1,3-DCP), 2,3-dichloropropanol (2,3-DCP) and 3-chloropropanediol (3-CPD). Production of wet-strength resins with reduced levels of epi by-products has been the subject of much investigation. Environmental pressures to produce wet-strength resins with lower levels of adsorbable organic halogen (AOX) species have been increasing. "AOX" refers to the adsorbable organic halogen content of the wet strength resin which can be determined by means of adsorption unto carbon. Accordingly, AOX includes epichlorohydrin (epi) and epi by-products (1,3-dichloropropanol, 2,3-dichloropropanol and 3-chloropropanediol) as well as organic halogen bound to the polymer backbone.

 Azetidinium-containing, polyaminopolyamide-epi resins have been treated with a basic ion exchange column to give a low AOX and low total chloride resin (WO/92/22601, assigned to Akzo NV). After this treatment, the resin was acidified. A disadvantage of this process is the ion exchange column has limited capacity and needs to be regenerated once the basicity is consumed. An additional disadvantage

is the resin has reduced effectiveness when treated with the basic ion exchange column.

Other technologies remove epi by-products but do not remove polymer-bound AOX (i.e., polymeric aminochlorohydrin). Polyaminopolyamide-epi resins have been
5 treated with microorganisms to reduce epi by-products to less than 10 ppm (EP 510987, assigned to Hercules Incorporated). This treatment, however, does not remove organic halogen bound to the polymer backbone. Another process to remove epi by-products uses a column of carbon adsorbent (WO 93/21384, assigned to E. I. duPont de Nemours). Such columns have limited capacity and
10 need to be regenerated once the adsorbent no longer efficiently removes the epi by-products.

Summary of the Invention

According to the present invention there is provided a process for reducing
15 the AOX content of a starting water-soluble wet-strength resin comprising azetidinium ions and tertiary aminohalohydrin, comprising treating said resin in aqueous solution with base to form treated resin, wherein at least about 20% of the tertiary aminohalohydrin present in the starting resin is converted into epoxide and the level of azetidinium ion is substantially unchanged, and the effectiveness of the
20 treated resin in imparting wet strength is at least about as great as that of said starting wet-strength resin.

Further provided is the water-soluble wet-strength resin prepared by the process of the present invention.

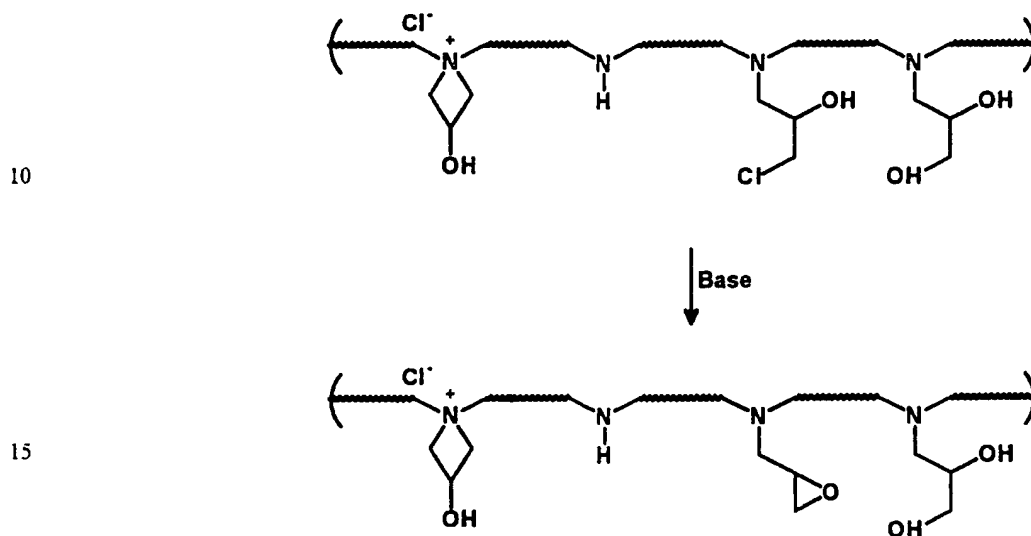
Still further provided is the process for preparing paper using the wet-strength
25 resin prepared by the present invention and the paper so made.

Detailed Description of Invention

It surprisingly has been discovered that the AOX content of azetidinium and aminochlorohydrin containing wet strength resins can be greatly reduced while

maintaining or even improving their wet strength characteristics. The starting water-soluble wet-strength resins of the present invention can be polyaminopolyamide-epi resins or polyalkylene polyamine-epi resins and mixtures thereof.

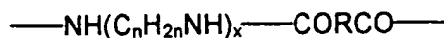
The conversion of the tertiary aminochlorohydrin (ACH) of the wet-strength resins of the present invention to tertiary epoxide by base treatment can be illustrated by the following formula:



Polyaminopolyamide-epichlorohydrin resins comprise the water-soluble polymeric reaction product of epichlorohydrin and polyamide derived from polyalkylene polyamine and saturated aliphatic dibasic carboxylic acid containing from about 3 to about 10 carbon atoms. It has been found that resins of this type impart wet-strength to paper whether made under acidic, alkaline or neutral conditions. Moreover, such resins are substantive to cellulosic fibers so that they may be economically applied thereto while the fibers are in dilute aqueous suspensions of the consistency used in paper mills.

In the preparation of the cationic resins contemplated for use herein, the dibasic carboxylic acid is first reacted with the polyalkylene polyamine, under

conditions such as to produce a water-soluble polyamide containing the recurring groups



where n and x are each 2 or more and R is the divalent hydrocarbon radical of the dibasic carboxylic acid. This water soluble polyamide is then reacted with epi to form the water-soluble cationic thermosetting resins.

The dicarboxylic acids contemplated for use in preparing the resins of the invention are the saturated aliphatic dibasic carboxylic acids containing from 3 to 10 carbon atoms such as succinic, glutaric, adipic, azelaic and the like. The saturated dibasic acids having from 4 to 8 carbon atoms in the molecule, such as adipic and glutaric acids are preferred. Blends of two or more of the saturated dibasic carboxylic acids may also be used.

A variety of polyalkylene polyamines including polyethylene polyamines, polypropylene polyamines, polybutylene polyamines, polypentylene polyamines, polyhexylene polyamines and so on and their mixtures may be employed of which the polyethylene polyamines represent an economically preferred class. More specifically, the polyalkylene polyamines contemplated for use may be represented as polyamines in which the nitrogen atoms are linked together by groups of the formula $\text{---C}_n\text{H}_{2n}\text{---}$ where n is a small integer greater than unity and the number of such groups in the molecule ranges from two up to about eight. The nitrogen atoms may be attached to adjacent carbon atoms in the group $\text{---C}_n\text{H}_{2n}\text{---}$ or to carbon atoms further apart, but not to the same carbon atom. This invention contemplates not only the use of such polyamines as diethylenetriamine, triethylenetetramine, tetraethylenepentamine, and dipropylenetriamine, which can be obtained in reasonably pure form, but also mixtures and various crude polyamine materials. For example, the mixture of polyethylene polyamines obtained by the reaction of ammonia and ethylene dichloride, refined only to the extent of removal of chlorides, water, excess ammonia, and ethylenediamine, is a satisfactory starting material. The term "polyalkylene polyamine" employed in the claims, therefore,

refers to and includes any of the polyalkylene polyamines referred to above or to a mixture of such polyalkylene polyamines and derivatives thereof.

It is desirable, in some cases, to increase the spacing of secondary amino groups on the polyamide molecule in order to change the reactivity of the polyamide-epichlorohydrin complex. This can be accomplished by substituting a diamine such as ethylenediamine, propylenediamine, hexamethylenediamine and the like for a portion of the polyalkylene polyamine. For this purpose, up to about 80% of the polyalkylene polyamine may be replaced by molecularly equivalent amount of the diamine. Usually, a replacement of about 50% or less will serve the purpose.

In converting the polyamide, formed as above described, to a cationic thermosetting resin, it is reacted with epichlorohydrin at a temperature from about 25°C, to about 100°C and preferably between about 35°C to about 70°C until the viscosity of a 20% solids solution at 25 °C has reached about C or higher on the Gardner Holdt scale. This reaction is preferably carried out in aqueous solution to moderate the reaction. Although not necessary, pH adjustment can be done to increase or decrease the rate of crosslinking.

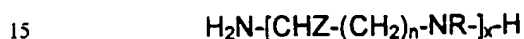
When the desired viscosity is reached, sufficient water is then added to adjust the solids content of the resin solution to the desired amount, i.e., about 15% more or less, the product cooled to about 25°C and then stabilized by adding sufficient acid to reduce the pH at least to about 6 and preferably to about 5. Any suitable acid such as hydrochloric, sulfuric, nitric, formic, phosphoric and acetic acid may be used to stabilize the product. However, hydrochloric acid and sulfuric acid are preferred.

In the polyamide-epichlorohydrin reaction, it is preferred to use sufficient epichlorohydrin to convert most of the secondary amine groups to tertiary amine groups. However, more or less may be added to moderate or increase reaction rates. In general, satisfactory results may be obtained utilizing from about 0.5 mole to about 1.8 moles of epichlorohydrin for each secondary amine group of the polyamide. It is preferred to utilize from about 0.6 mole to about 1.5 moles for each secondary amine group of the polyamide.

Epichlorohydrin is the preferred epihalohydrin for use in the present invention. The present application refers to epichlorohydrin specifically in certain instances, however, the person skilled in the art will recognize that these teachings apply to epihalohydrin in general.

5 Cationic water-soluble resins, derived from the reaction of epihalohydrins, such as epichlorohydrin, and polyalkylene polyamines, such as ethylenediamine (EDA), bis-hexamethylenetriamine (BHMT) and hexamethylenediamine (HMDA) have long been known. These polyalkylene polyamine-epihalohydrin resins are described in patents such as U.S. Patent 3,655,506 to J. M. Baggett, et al. and
10 others such as U.S. Patent 3,248,353 and U.S. Patent No. 2,595,935 to Daniel et al. from which their generic description as "Daniel's Resins" arises.

 The polyalkylene polyamine employed in the present invention is selected from the group consisting of polyalkylene polyamines of the formula:



 where:

$n = 1-7,$

$x = 1-6$

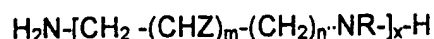
$\text{R} = \text{H or CH}_2\text{Y},$

20 $\text{Z} = \text{H or CH}_3,$

 and

$\text{Y} = \text{CH}_2\text{Z}, \text{H}, \text{NH}_2, \text{ or CH}_3,$

polyalkylene polyamines of the formula:



where:

$m=1-6$, $n=1-6$, and $m+n = 2-7$,

5 $R=\text{H}$ or CH_2Y ,

$Z= \text{H}$ or CH_3 ,

and

$\text{Y}=\text{CH}_2\text{Z}$, H , NH_2 , or CH_3 ,

and mixtures thereof.

10

Polyalkylene polyamine-epihalohydrin resins comprise the water-soluble polymeric reaction product of epihalohydrin and polyalkylene polyamine. In making Daniel's Resins the polyalkylene polyamine is added to an aqueous mixture of the epihalohydrin so that during the addition the temperature of the mixture does not exceed 60°C. Lower temperatures lead to further improvements, though too low a temperature may build dangerously latent reactivity into the system. The preferred temperatures fall within the range of about 25°C to about 60°C. More preferred is a range of from about 30°C to about 45°C.

15

Alkylation of the polyamine occurs rapidly proceeding to form secondary and tertiary amines depending on the relative amounts of epihalohydrin and polyamine. The levels of epihalohydrin and polyamine are such that between about 50 and 100% of the available amine nitrogen sites are alkylated to tertiary amines. Preferred levels are between about 50 and about 80% alkylation of the amine nitrogen sites. Excess epihalohydrin beyond that required to fully alkylate all the amine sites to the tertiary amine is less preferred because this results in increased production of epihalohydrin byproducts.

20

25

To minimize epi byproducts and AOX, preferably time spent combining the polyamine and epichlorohydrin should be minimized. This is required to minimize the period during the combining of reactants, in which there is a significant level of

unalkylated or partially alkylated polyamine in the presence of uncombined epichlorohydrin. This condition results in an alkaline system in which conversion to epihalohydrin by-products is accelerated. Through experience, it has been found that the time for addition of at least about 90% by weight of the polyamine, while
5 maintaining the reaction temperature within the specified range, should not exceed 150 minutes if 1,3-DCP levels are to be kept below the maximum levels desired. A more preferred addition time is 120 minutes or less for addition of at least about 90% of the amine, with 100 minutes or less time of addition being most preferred. Once about 90% of the polyamine is added then the time of addition of the remainder
10 becomes less important. This condition is specifically related to the completion of the alkylation reaction between the polyamine and the epihalohydrin, at which point practically all of the epihalohydrin has been consumed in alkylating the polyamine.

Following complete addition of the polyamine, the temperature of the mixture is allowed to rise and /or the mixture is heated to effect crosslinking and azetidinium
15 formation. The crosslinking rate is a function of concentration, temperature, agitation, and the addition conditions of the polyamine all of which can be readily determined by those skilled in the art. The crosslinking rate can be accelerated by the addition of small shots of the polyamine or other polyamines of the present invention or addition of various alkalies at or near the crosslinking temperature.

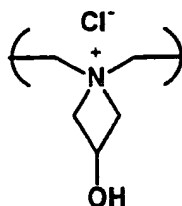
20 The resin is stabilized against further crosslinking to gelation by addition of acid, dilution by water, or a combination of both. Acidification to pH 5.0 or less is generally adequate.

The preferred polyamines are bis-hexamethylenetriamine, hexamethylenediamine, and their mixtures.

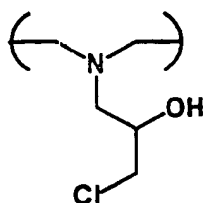
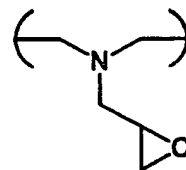
25 A wide range of aminochlorohydrin (ACH) and azetidinium (AZE) levels is possible with polyaminopolyamide-epi and polyamine-epi resins and is suitable for use in this invention. The ratio of ACH:AZE is at least about 2:98, preferably at least about 5:95 and most preferably at least about 10:90. The ACH:AZE ratio can be up to about 98:2, preferably up to about 95:5 and most preferably up to about 90:10.

The starting water-soluble wet-strength resins of the present invention always contain tertiary ACH. Optionally, they may additionally contain secondary ACH and/or quaternary ammonium chlorohydrin also.

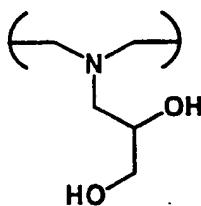
The following structures illustrate functionalities referred to in the present application. The ACH, epoxide, glycol and amine crosslinking functionalities are illustrated in terms of their tertiary species.



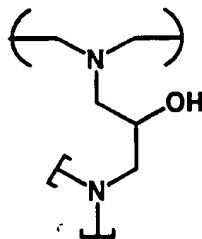
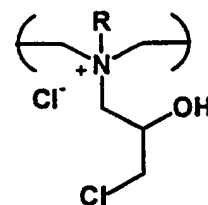
azetidinium

tertiary
aminochlorohydrin

tertiary epoxide



tertiary glycol

tertiary amine
crosslinkingquaternary ammonium
chlorohydrin (R = alkyl)

By the process of the present invention generally at least about 20% of the aminochlorohydrin present in the starting resin has been converted into epoxide. Preferably at least about 50% and most preferably at least about 90% of the aminochlorohydrin present in the starting resin has been converted to epoxide. By the present invention up to about 100% of the aminochlorohydrin present in the starting resin can be converted to epoxide.

It should be understood that the phrase "aminohalohydrin" as used in the present application can refer to secondary aminohalohydrin, tertiary aminohalohydrin and quaternary ammonium halohydrin unless otherwise specified.

It should also be understood that the phrase "epoxide" and "aminoepoxide" are used interchangeably in the present application and they refer to secondary aminoepoxide, tertiary aminoepoxide and quaternary aminonium epoxide unless otherwise specified.

5 Both organic and inorganic bases can be used herein in the present invention. A base is defined as any proton acceptor (see *Advanced Organic Chemistry, Third Ed.*; Jerry March; John Wiley & Sons: New York, 1985, p 218-236, incorporated herein by reference.) Typical bases include alkali metal hydroxides, carbonates and bicarbonates, alkaline earth metal hydroxides, trialkylamines, tetraalkylammonium
10 hydroxides, ammonia, organic amines, alkali metal sulfides, alkaline earth sulfides, alkali metal alkoxides and alkaline earth alkoxides. Preferably, the base will be alkali metal hydroxides (lithium hydroxide, sodium hydroxide and potassium hydroxide) or alkali metal carbonates (sodium carbonate and potassium carbonate). Most preferably, the base is sodium hydroxide or potassium hydroxide.

15 The amount of base varies widely from resin to resin and is dependent on the resin type, the amount and type of polymeric aminochlorohydrin, the amount of the epi by-products (1,3-dichloropropanol, 2,3-dichloropropanol and 3-chloropropanediol), the amount of stabilization acid in the resin and on the conditions used to activate the resin. The amount of base can be at least about 0.5 mmole, preferably at least about 1.5 mmole per dry gram of resin. The amount of base can
20 be up to about 10 mmole, preferably up to about 8 mmole per dry gram of resin. The pH can be from 13.0-8.0, preferably 12.5-9.0, more preferably 12.0-10.0, most preferably 11.5-10.5.

The treatment temperature can be at least about 0°C, preferably at least
25 about 20°C, preferably at least about 40°C, more preferably at least about 45°C and most preferably at least about 50°C. The treatment temperature can be up to about 100°C, preferably up to about 80°C and most preferably up to about 60°C. The treatment time can be at least about 1 minute, preferably at least about 3 min, and most preferably at least about 5 min. The treatment time can be up to about 24

hours, preferably up to about 4 hours and most preferably up to about 1 hour. The resin can be used about 1 minute to about 24 hours after base treatment, preferably about 1 minute to about 6 hours, most preferably about 1 minute to about 1 hour. The resin solids for base treatment can be at least about 1%, preferably at least about 2%, preferably at least about 6%, more preferably at least about 8% and most preferably at least about 10% based upon the weight of the composition. In the context of the present invention the phrase "resin solids" means the active polyaminopolyamide-epi and/or polyalkylene polyamine-epi of the composition. The resin solids for base treatment can be up to about 40%, preferably up to about 25%, and most preferably up to about 15%. After base treatment, the resin can be diluted, typically, with water.

For most high molecular weight resins the preferred treatment conditions convert greater than 90% of the aminochlorohydrin functionality to epoxide functionality, with less than a 10% reduction in the amount of azetidinium functionality. For some resins, especially ones with low molecular weight, it may be preferred to allow some or all of the epoxide functionality be consumed by crosslinking reactions. Less preferred treatment conditions are such that greater than 5 mole % of the azetidinium and/or epoxide is converted to glycol functionality. This conversion reduces the total amount of reactive functionality which, generally, reduces the effectiveness of the treated resin. To have a highly effective resin, the mole % hydrolysis of total reactive functionality (azetidinium, epoxide and/or aminochlorohydrin) to glycol is from about 0% up to about 20%, preferably up to about 10%, more preferably up to about 5% and most preferably up to about 2%. To have a highly effective resin, the level of azetidinium ion in the treated resin will be substantially unchanged compared to the level before treatment. In the context of the present invention this means that the treated resin will have at least about 80 mole % of the azetidinium functionality in the untreated resin, preferably about 90 mole %, more preferably about 95 mole % and most preferably about 100 mole %.

The wet strength effectiveness of the treated resin of the present invention will not be substantially lowered by the base treatment. In the context of the present invention this means that the treated resin will have at least about 80% of the effectiveness of the untreated resin, preferably at least about 95% and most preferably about 100%. With resins containing more than about 5 mole % of aminohalohydrin, the present invention may provide a treated resin with effectiveness greater than the untreated resin. The effectiveness improvement can be from about 2-50%, preferably the improvement would be greater than about 5% and most preferably greater than about 10%.

The treatment conditions for each resin can be optimized to a given set of conditions, however, one skilled in the art will recognize that other conditions will also give good results. For example, if a shorter reaction time is desired, then a higher temperature could be used with good results.

The treatment conditions can reduce the AOX content to less than 50%, preferably less than 25%, preferably less than 10%, preferably less than 5%, more preferably less than 1%, most preferably, less than 0.5% of the AOX content in the untreated resin on an equal solids level basis. Although the focus of the present invention is to reduce AOX, it can also be used to reduce the levels of the epichlorohydrin (epi) by-products, 1,3-dichloropropanol (1,3-DCP), 2,3-dichloropropanol (2,3-DCP) and 3-chloropropanediol (3-CPD), in polyaminopolyamide-epi resins or polyalkylene polyamine-epi resins. Additionally, the present invention could be used to convert 1,3-DCP and 2,3-DCP to epi. This epi could be removed from the resin by further treatment, for example, by distillation or extraction.

Gas chromatography (GC) was used to determine epi and epi by-products in the treated and untreated resins using the following method. The resin sample was absorbed onto an extrelut column (available from EM Science, Extrelut QE, Part #901003-1) and extracted by passing ethyl acetate through the column. A portion of the ethyl acetate solution was chromatographed on a wide-bore, capillary column. If

the flame ionization detector was used, the components were quantitated using n-octanol as the internal standard. If an electrolytic conductivity (ELCD) detector or if the XSD detector was used, an external standard method using peak matching quantitation was employed. The data system was either a millennium 2010 or HP ChemStation. The FID detector was purchased from Hewlett-Packard (HP). The
5 ELCD detector, Model 5220, was purchased from OI Analytical. The XSD detector was purchased from OI Analytical, Model 5360 XSD. The GC instrument used was a HP Model 5890 series II. The column was DB wax 30 m x 53 mm with 1.5 micron film thickness. For the FID and ELCD, the carrier gas was helium with a flow rate of
10 10 mL/min. The oven program was 35°C for 7 minutes, followed by ramping at 8°C/min to 200°C and holding at 200°C for 5 minutes. The FID used hydrogen at 30 mL/min and air at 400 mL/min at 250°C. The ELCD used n-propanol as the electrolyte with an electrolyte flow rate setting of 50% with a reactor temperature of 900°C. The XSD reactor was operated in an oxidative mode at 1100°C with a high
15 purity air flow rate of 25 mL/min.

Kymene® ULX wet-strength resin is a polyaminopolyamide-epi resin available from Hercules Incorporated. The first sample used had a resin solids of 12.7% and a charge density of 3.36 meq/g at pH 1.8, 1.73 meq/g at pH 8 and 1.51 meq/g at pH
10. The second sample of Kymene® ULX wet strength resin used had a resin solids
20 of 12.7% and a charge density of 3.28 meq/g at pH 1.8, 1.72 meq/g at pH 8 and 1.56 meq/g at pH 10.

E7045 wet-strength resin is a polyaminopolyamide-epi resin available from Hercules Incorporated. The sample used had a charge density of 3.34 meq/g at pH 1.8, 1.96 meq/g at pH 8 and 0.89 meq/g at pH 10 and a total solids of 13.0%.

25 Kymene® 557LX wet-strength resin is a polyaminopolyamide-epi resin available from Hercules Incorporated. It had a pH of 3.5, a total solids of 12.5%, and a Brookfield viscosity of 47 cps. It had a charge density of 1.39 meq/g at pH 10.

Kymene® 736 wet-strength resin is a polyalkylene polyamine-epi resin available from Hercules Incorporated. It had a pH of 3.3, a total solids of 37.8%, and a Brookfield viscosity of 250 cps. It had a charge density of 2.24 meq/g at pH 8.

5 Kymene® ULX2 wet-strength resin is a polyaminopolyamide-epi resin available from Hercules Incorporated.

The scope of this invention as claimed is not limited by the following examples, which are given merely by way of illustration. All parts and percentages are by weight unless otherwise indicated.

10 **EXAMPLE 1, 1b and COMPARATIVE EXAMPLE 1**

Base treatment of Kymene® ULX wet strength resin

To 48.15 g (wet basis) of Kymene® ULX resin, first sample, (12.7% resin solids) was added 6.25 g of deionized water. Magnetic stirring was started and the solution was heated to 55°C with a water bath fitted with a Cole-Parmer Polystat®
15 temperature controller. The pH was monitored with a Beckman 10 pH meter connected to an automatic temperature compensator and a Ross pH electrode, sure flow. The pH meter was calibrated daily with pH 7 and 10 buffer solutions. To the Kymene® ULX solution was injected 6.72 g (6.11 mL) of 10% (wt/wt) aqueous
20 sodium hydroxide. (This gave a solution with 10% resin solids). The peak pH was 10.9 and the temperature dropped to 54°C for about one minute. The pH was 10.1 after 5 minutes at which time the resin was cooled rapidly to room temperature and analyzed by ¹³C NMR and for AOX (see Table 1). A Mitsubishi Kasei Corporation instrument (model TOX-10Σ) was used for the AOX analysis, using the procedure
25 described in the operating manual. The ¹³C NMR spectra are acquired using BRUKER AMX spectrometers equipped with a 10mm broadband probe. A ¹³C NMR operating frequency of 100 MHz (AMX400) or 125 MHz (AMX500) is sufficient for data collection. In either case, the spectra are acquired with continuous ¹H decoupling. Electronic integration of the appropriate signals provides molar

concentrations of the following alkylation components; ACH, EPX, GLY, and AZE.

where:

ACH=polymeric aminochlorohydrins

EPX=polymeric epoxides

GLY=polymeric glycols

AZE=azetidinium ions

In order to calculate the concentrations of each of these species, the integral values must be placed on a one (1) carbon basis. For example, the spectral region between 20-42 ppm represents six (6) carbons of the diethylenetriamine-adipate backbone, hence the integral value is divided by six. This value is used as the polymer common denominator (PCD) for calculation of the alkylation species. The chemical shifts of these species are provided below (using an acetonitrile field reference of 1.3 ppm). The corresponding integral value of each alkylation product is used in the numerator for calculation, refer to examples below:

-ACH signal at 68-69 ppm represents one carbon;

$\text{integral of ACH} \div \text{PCD} = \text{mole fraction ACH}$

-GLY signal at 69-70 ppm represents one carbon;

$\text{integral of GLY} \div \text{PCD} = \text{mole fraction GLY}$

-EPX carbon at 51-52ppm represents one carbon;

$\text{integral of EPX} \div \text{PCD} = \text{mole fraction EPX}$

-AZE signal at 73-74 ppm represents two carbons, thus, a division factor of two is required;

$\text{integral of AZE}/2 \div \text{PCD} = \text{mole fraction AZE}$

The following spectral parameters are standard experimental conditions for ^{13}C NMR analysis of base treated Kymene resins on the Bruker AMX400.

Temperature	25°C
Resonance Frequency	100MHz
# Data Points	64K
Dwell Time	20 microseconds
Acquisition Time	1.3 seconds
Sweep Width	25000 Hz
Number of Scans	1K
Relaxation Delay	3 seconds
Pulse Tip Angle	70 degrees
Pulse Program	zgdc
Processed Spectral Size	64K
Apodization Function	exponential
Line Broadening	3 Hz

Paper handsheets were prepared on a Noble and Wood handsheet machine at pH 7.5 with 50:50 Rayonier bleached Kraft:James River bleached hardwood Kraft dry lap pulp refined to 500 mL Canadian standard freeness. Sheets were generated having 40 lb/3000 sq. ft. basis weight containing 0.5-1.0% of treated resin (based on the solids of untreated resin). Handsheets were wet pressed to 33% solids and dried on a drum drier at 230°C for 55 seconds. Natural aging refers to paper conditioned according to TAPPI Method T-402. All paper tested had greater than two weeks natural aging at 50% \pm 2% relative humidity and at 23°C \pm 1°C.

Dry tensile strength was determined using TAPPI Method T-494. Wet tensile strength was determined using TAPPI Method T-456 with a two hour soak time.

As can be seen in Table 1, on an equal solids basis, the AOX content of Kymene® ULX resin was reduced from 2600 ppm (Comparative Example 1) to 35 ppm (Example 1) by the base treatment process in this invention. Example 1b employed the same conditions as Example 1 except the reaction time was 30 minutes. Base treated Kymene® ULX resin had 99-109% of the effectiveness of untreated Kymene® ULX resin for cured and natural aged handsheets at 0.5% and 1.0% addition levels. (See Tables 7 and 8). Employing the conditions of Example 1, the polymeric chlorohydrin functionality was cleanly converted to epoxide functionality without a significant reduction in the amount of azetidinium functionality, as determined by ^{13}C NMR. This increase in total reactive functionality (epoxide and azetidinium) resulted in the high effectiveness of this base treated resin. Besides the low AOX and high effectiveness advantages, an additional advantage over the prior art is that no additional process step is needed, for example, regeneration of an ion exchange or carbon column.

EXAMPLES 2-9

Kymene® ULX was treated as in Example 1, except as shown in Table 1. The unreacted aminochlorohydrin (ACH) in Examples 2 and 4 shows that the conditions did not give optimal AOX reduction. It is understood by one skilled in the

art that ACH is a contributor of AOX and that an AOX determination is not needed when ACH is present. It is also understood that epoxide functionality is more reactive than ACH functionality and that additional epoxide functionality in a resin will increase the wet strength effectiveness of the resin in many applications. Example 3 shows that longer reaction time did not significantly reduce the level of ACH but the epoxide was consumed. At an equal base amount as in Example 1, Examples 5 and 6 show that lower temperature leads to incomplete conversion of ACH even after a 4 hour reaction time. Examples 8 and 9 show that sodium carbonate and calcium hydroxide can be used to reduce AOX, but they are less effective, all other conditions being equal.

EXAMPLES 10-12 AND COMPARATIVE EXAMPLE 2

A different lot (second sample) of Kymene® ULX wet strength resin (Comparative Example 2) was treated as in Example 1, except as shown in Table 2. Example 10 shows that Example 1 could be reproduced with a different lot of Kymene® ULX resin. Relative to Example 10, Example 12 shows that a similar result can be obtained using a lower temperature (40°C) and a longer reaction time (30 min). Compared to Example 11, Example 12 shows that a 30 min reaction time at 40°C gave an AOX reduction closer to optimum. As can be seen in Table 9, on an equal solids basis, the level of epichlorohydrin by-products in the Kymene® ULX resin was also reduced by the base treatment process in this invention. For example, the 3-chloropropanediol (3-CPD) level was reduced from 57 ppm (Comparative Example 2) to 6 ppm (Example 10).

EXAMPLE 13 AND COMPARATIVE EXAMPLE 3

Base treatment of E7045 wet strength resin

The procedure and equipment used to treat E7045 resin (which is an polyaminopolyamide-epi resin available from Hercules Incorporated, Comparative Example 3) were the same as in Example 1, except for the following changes. To

47.15 g (wet basis) of E7045 resin was added 7.28 g of deionized water. Magnetic stirring was started and the solution was heated to 55°C. To the solution was injected 6.72 g (6.11 mL) of 10% (wt/wt) aqueous sodium hydroxide. The peak pH was 10.8. The pH was 10.1 after 5 minutes at which time the resin was cooled rapidly to room temperature and analyzed by ¹³C NMR and for AOX (see Table 3). Compared to Comparative Example 3, the base treatment process of Example 13 reduced the AOX level while maintaining the azetidinium (AZE) level. As can be seen in Table 9, on an equal solids basis, the level of epichlorohydrin by-products in E7045 resin was also reduced by the base treatment process in this invention. For example, the 3-chloropropanediol (3-CPD) level was reduced from 188 ppm (Comparative Example 3) to 10 ppm (Example 13).

EXAMPLES 14-20 AND COMPARATIVE EXAMPLE 4

Base treatment of Kymene® 557LX wet strength resin (Example 17)

The procedure and equipment used to treat Kymene® 557LX polyaminopolyamide-epi resin (Comparative Example 4) were the same as in Example 1, except for the following changes. To 48.92 g (wet basis) of Kymene® 557LX resin was added 6.36 g of deionized water. Magnetic stirring was started and the solution was heated 55°C. To this solution was injected 5.87 g (5.87 mL) of 10% (wt/wt) aqueous sodium hydroxide. The peak pH was 10.9. The pH was 10.2 after 5 minutes at which time the resin was cooled rapidly to room temperature and analyzed by ¹³C NMR and for AOX (see Table 4). The procedure for Examples 14, 15, 16, 18, 19 and 20 was similar to Example 17 except as indicated in Table 4. In Example 16, the base treatment process of Kymene® 557LX resin resulted in a resin with slightly decreased effectiveness, 89-101% of Kymene® 557LX resin, with 188 ppm (corrected to 12.5% solids) of AOX (see Tables 7 and 8). The AOX and NMR results suggested that this resin was overtreated, so using less sodium hydroxide would have improved effectiveness. Example 17 showed that less base (2.4 mmole NaOH/g dry resin versus 2.8) could be used with a comparable AOX reduction and

with only a 4% decrease in AZE (see Table 4). Example 18 shows that further reduction in the amount of base (to 2.0 mmole of NaOH/g dry resin) leads to incomplete conversion of ACH to epoxide with the resulting increase in AOX (see Table 4). From these results, under the same reaction conditions, the optimum amount of base is greater than about 2.0 and less than about 2.8 mmole of NaOH/g dry resin. Examples 19 and 20 show that a lower temperature and a longer reaction time is less effective in reducing AOX compared to Example 18. As can be seen in Table 9, on an equal solids basis, the total level of epichlorohydrin and epichlorohydrin by-products in the Kymene® 557LX wet-strength resin was also reduced by the base treatment process in this invention. For example, the 3-chloropropanediol (3-CPD) level was reduced from 190 ppm (Comparative Example 4) to 163 ppm (Example 18) and the 1,3-dichloropropanol (1,3-DCP) level was reduced from 800 ppm to 14 ppm.

EXAMPLES 21-22 AND COMPARATIVE EXAMPLE 5

Synthesis of Poly(adipic acid-co-diethylenetriamine)

A resin kettle was fitted with a heavy duty mechanical stirrer, a Dean-Stark trap/water condenser, a temperature controller, and a nitrogen sparge. To the flask was charged 297.13 g (2.88 mole) of diethylenetriamine (Aldrich, 99%) and then 438.42 g (3.00 mole) of adipic acid (Aldrich, 99%) was slowly added so as to maintain the exotherm below 120°C. The yellow pasty mixture was slowly heated to 170-173°C over 3 hours. Water started to collect at about 150°C. After an additional 2 hours at 170-173°C, the viscous polymer was allowed to cool to about 145°C and 465 g of deionized water was carefully added. The solution was allowed to cool to ambient temperature and was bottled. [Total solids 60.37%, Intrinsic viscosity (IV) = 0.160 in 1 M ammonium chloride at 25°C.]

Synthesis of polyaminopolyamide-epi resin containing about 13 mole % of azetidinium (Comparative Example 5)

A 500-mL flask was fitted with a condenser, a pH meter, a temperature controller and heating mantle, an addition funnel and a mechanical stirrer. To the flask was added 105.99 g (63.98 g solids, 0.30 mole, IV = 0.160) of 60.37% aqueous poly(adipic acid-co-diethylenetriamine) synthesized above and 53.97 g of deionized water (to give 40% solids). The solution was heated to 30°C with a temperature controlled water bath and then 24.98 g (0.27 mole) of epichlorohydrin (Aldrich, 99%) was added over 3 minutes. The temperature was raised to 35°C. The pH dropped from 9.4 to 7.6 over the course of the reaction. After 5 hours at 35°C, 526.8 g of deionized water was added and the pH was adjusted to 2.9 with 11.42 g of concentrated sulfuric acid. Analyses: total solids, 13.56%; AOX, 0.96%.

Base treatment of polyaminopolyamide-epi resin of Comparative Example 5 (Example 21)

The procedure and equipment used to activate Comparative Example 5 were the same as in Example 1 except as shown in Table 5 and as follows. To 45.10 g (wet basis) of Comparative Example 5 was added 3.82 g of deionized water. Magnetic stirring was started and the solution was heated to 55°C. To this solution was injected 12.22 g of 10% (wt/wt) aqueous sodium hydroxide. The peak pH was 11.6. The pH was 10.9 after 5 minutes at which time the resin was cooled rapidly to room temperature and analyzed by ¹³C NMR and for AOX (see Table 5). Example 22 was prepared as in Example 21 except as noted in Table 5. Example 21 shows that the ACH functionality was cleanly converted to epoxide functionality. The level of AOX was greatly reduced from 9600 ppm in Comparative Example 5 (i.e., untreated resin) to 244 ppm in Example 21. This resin dramatically increased in effectiveness upon base treatment to 121-134% of the untreated resin in a handsheet evaluation (see Tables 7 and 8). Example 22 shows conditions that result in incomplete conversion of ACH functionality and in less than optimum

reduction in AOX. As can be seen in Table 9, on an equal solids basis, the total level of epichlorohydrin and epichlorohydrin by-products in this resin was also reduced by the base treatment process in this invention. For example, the 3-chloropropanediol (3-CPD) level was reduced from 528 ppm (Comparative Example 5) to 132 ppm (Example 22) and the 1,3-dichloropropanol (1,3-DCP) level was reduced from 896 ppm to 23 ppm.

EXAMPLES 23-28 and COMPARATIVE EXAMPLE 6

Base treatment of Kymene® 736 wet strength resin (Example 24)

The procedure and equipment used to treat Kymene® 736 polyamine-epi wet strength resin (Comparative Example 6) were the same as in Example 1 except as follows. To 15.8 g (wet basis) of Kymene® 736 resin was added 35.75 g of deionized water. Magnetic stirring was started and the solution was heated to 55°C. To this solution was injected 9.60 g (8.73 mL) of 10% (wt/wt) aqueous sodium hydroxide. The peak pH was 10.3. The pH was 9.1 after 5 minutes at which time the resin was cooled rapidly to room temperature and analyzed by ¹³C NMR and for AOX (see Table 6). Examples 23, 25, 26, 27 and 28 were the same as Example 24 except as noted in Table 6. Example 24 shows that, relative to the Comparative Example 6, the level of AOX (the level of ACH being an indicator of the level of AOX) was reduced with only a slight reduction in the level of azetidinium. Example 23 shows that a lesser amount of base (all other conditions being equal) resulted in incomplete conversion of ACH, which, if measured, would give a higher AOX level. Example 25 shows the level of AOX reduction achievable with this process. Example 25 and 26 shows that increasing the level of base (all other conditions being equal) resulted in a reduction in the amount of azetidinium relative to Example 24. This reduction would be expected to reduce the effectiveness of the resin. Example 27 shows that increasing the pH of Kymene® 736 resin to 8.0 results in only a slight decrease in the level of ACH. Lower temperature reaction (Example 28) gives comparable ¹³C NMR results as in Example 25, but the level of AOX is higher.

As can be seen in Table 9, on an equal solids basis, the total level of epichlorohydrin and epichlorohydrin by-products in the Kymene® 736 wet-strength resin was also reduced by the base treatment process in this invention. For example, the 3-chloropropanediol (3-CPD) level was reduced from 175 ppm (Comparative Example 6) to 53 ppm (Example 25) and the 1,3-dichloropropanol (1,3-DCP) level was reduced from 1000 ppm to 8 ppm.

EXAMPLE 29 and COMPARATIVE EXAMPLE 7

Base treatment of Kymene® ULX2 wet strength resin

To 62.50 g (wet basis) of Kymene® ULX2 resin (12.8% resin solids) was added 8.70 g of deionized water. Magnetic stirring was started and the solution was heated to 55°C with a water bath fitted with a Cole-Parmer Polystat® temperature controller. The pH was monitored with a Beckman 10 pH meter connected to an automatic temperature compensator and a Ross pH electrode, sure flow. The pH meter was calibrated daily with pH 7 and 10 buffer solutions. To the Kymene® ULX2 solution was injected 8.80 g (8.00 mL) of 10% (wt/wt) aqueous sodium hydroxide. (This gave a solution with 10% resin solids). The peak pH was 10.4. The pH was 10.1 after 5 minutes at which time the resin was cooled rapidly to room temperature and analyzed by gas chromatography (GC) (see Table 9).

As can be seen in Table 9, on an equal solids basis, the level of epichlorohydrin by-products in the Kymene® ULX2 resin was reduced by the base treatment process in this invention. For example, the 3-chloropropanediol (3-CPD) level was reduced from 2.5 ppm (Comparative Example 7) to 0.5 ppm (Example 29).

TABLE 1⁽⁴⁾Analysis of Base Treated Kymene® ULX Wet-Strength Resin by ¹³C NMR and AOX

Example	Treatment Conditions	mmole NaOH/ g resin (dry)	AOX (ppm) (equal solids basis) ⁽¹⁾	% AZE ⁽²⁾	% ACH ⁽³⁾	% Glycol	Percent Epoxide	% Tertiary Amine
Comp Ex. 1	Untreated	None	2600	37.2	7.0	2.8	0.0	17.0
Ex. 1	55°C for 5 min	2.8, peak pH: 10.9	35	36.2	0.0	4.8	8.4	20.9
Ex. 2	25°C for 5 min	2.3, peak pH: 9.9	-----	39.0	5.5	3.9	4.2	17.7
Ex. 3	25°C for 24 h	2.3, 4 h pH: 9.6	-----	36.2	5.2	4.8	0.0	21.4
Ex. 4	55°C for 5 min	2.3, peak pH: 10.4	743	36.4	3.8	3.9	4.4	21.3
Ex. 5	25°C for 5 min	2.8, peak pH: 11.7	-----	36.9	0.9	4.5	7.7	23.4
Ex. 6	25°C for 4 h	2.8 4 h pH: 10.6	-----	34.5	0.7	3.5	7.1	23.7
Ex. 7	55°C for 5 min	3.3, peak pH: 11.1	-----	35.8	0.0	6.3	6.5	24.1
Ex. 8	55°C for 5 min	3.3 (Na ₂ CO ₃),	1226	-----	-----	-----	-----	-----
Ex. 9	55°C for min	0.79 (Ca(OH) ₂)	2477	-----	-----	-----	-----	-----

(1) AOX = adsorbable organic halogen,

(2) AZE = azetidinium,

(3) ACH = aminochlorohydrin

(4) all AZE, ACH, Glycol, Epoxide and Tertiary Amine percentages are mole percent based on the resin in this and all other Tables.

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TABLE 2

5 Analysis of Base Treated Kymene® ULX Wet-Strength Resin by ¹³C NMR and AOX

Example	Treatment Conditions	mmole NaOH/ g resin (dry)	AOX (ppm) (equal solids basis)	% AZE	% ACH	% Glycol	Percent Epoxide	% Tertiary Amine
Comp. Ex. 2	Untreated	none	2500	43.1	6.3	2.5	0.0	13.9
Ex. 10	55°C for 5 min	2.8, peak pH: 10.7	11	41.9	0.0	2.8	5.8	16.7
Ex. 11	40°C for 5 min	2.8, peak pH: 10.7	83	-----	-----	-----	-----	-----
Ex. 12	40°C for 30 min	2.8, peak pH: 10.7	12	40.4	0.0	3.2	5.5	15.9

TABLE 3

10 Analysis of Base Treated E7045 Wet-Strength Resin by ¹³C NMR and AOX.

Example	Treatment Conditions	mmole NaOH/ g resin (dry)	AOX (ppm) (equal solids basis)	% AZE	% ACH	% Glycol	Percent Epoxide	% Tertiary Amine
Comp. Ex. 3	Untreated	none	880	35.4	0.8	1.3	0.0	8.8
Ex. 13	55°C for 5 min	2.8, peak pH: 10.8	78	35.7	0.0	2.5	0.0	10.1

TABLE 4

15 Analysis of Base Treated Kymene® 557LX Wet-Strength Resin by ^{13}C NMR and AOX

Example	Treatment Conditions	mmole NaOH/ g resin (dry)	AOX (ppm) (equal solids basis)	% AZE	% ACH	% Glycol	Percent Epoxide	% Tertiary Amine
Comp. Ex. 4	Untreated	None	3200	51.6	8.8	1.9	0.0	12.9
Ex. 14	25°C for 10 min	1.6, peak pH 10.7	2500	49.5	7.8	1.0	1.6	12.7
Ex. 15	25°C for 4 h	1.6, 4 h pH 8.8	1750	49.2	7.5	0.9	1.5	11.8
Ex. 16	55°C for 5 min	2.8, peak pH: 11.4	188	44.8	0.0	2.0	7.3	19.0
Ex. 17	55°C for 5 min	2.4, peak pH: 10.9	200	47.5	0.0	1.7	7.9	19.5
Ex. 18	55°C for 5 min	2.0, peak pH: 10.4	663	51.0	1.5	0.7	5.0	21.3
Ex. 19	25°C for 5 min	2.0, peak pH: 11.3	1663	51.5	3.0	1.0	4.1	21.1
Ex. 20	25°C for 4 h	2.0, 4 h pH: 9.4	763	-----	----	----	---	---

TABLE 5

Analysis of Base Treated Comparative Example 5 by ^{13}C NMR and AOX

Example	Treatment Conditions	Mmole NaOH/ g resin (dry)	AOX (ppm) (equal solids basis)	%AZE	%ACH	%Glycol	Percent Epoxide	% Tertiary Amine
Comp. Ex. 5	Untreated	None	9600	13.1	54.8	ND	0.0	52.8
Example 21	55°C for 5 min	5.0 peak pH 11.6	244	11.8	0.0	ND	53.4	59.2
Example 22	55°C for 5 min	4.3, peak pH 11.2	759	12.8	5.1	0.7	39.1	53.7

TABLE 6

Analysis of Base Treated Kymene® 736 Wet-Strength Resin by ^{13}C NMR and AOX

Example	Treatment Conditions	mmole NaOH/g resin (dry)	AOX (ppm) (10% solids basis)	% AZE	% ACH	% Glycol	Percent Epoxide
Comp. Ex. 6	Untreated	none	4820	42	30	<2	<2
Ex. 23	55°C for 5 min	2.8, peak pH: 9.8	----	41	8-10	<5	14
Ex. 24	55°C for 5 min	3.9, peak pH: 10.3	----	41	<2	<5	14
Ex. 25	55°C for 5 min	4.3, peak pH: 10.8	165	38	<2	5-10	13
Ex. 26	55°C for 5 min	5.1, peak pH: 11.1	---	32	<2	10-20	7
Ex. 27	25°C for 5 min	pH adjusted to 8.0	----	42	28	<2	1
Ex. 28	25°C for 5 min	4.3, peak pH: 11.8	770	37	<2	5-10	13

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TABLE 7
Handsheet Evaluation of Base Treated Resin (Paper was Naturally Aged)

Example	% Resin Added	Basis Wt. (lbs/3000 sq. ft.)	Caliper (mils)	Dry ⁽¹⁾ Tensile (lbs/in)	Wet ⁽¹⁾ Tensile (lbs/in)	% Wet/Dry Str.	Wet Strength % ⁽²⁾
Blank	0.0	40.7	4.88	17.49	0.50	3	-----
Comp. Ex. 1	0.5	40.0	5.00	21.00	3.95	19	-----
Comp. Ex. 1	1.0	40.2	5.07	21.69	4.90	23	-----
Ex. 1	0.5	40.8	4.88	20.59	3.89	19	99
Ex. 1	1.0	38.9	4.95	21.29	5.05	24	103
Ex. 1b	0.5	39.8	4.93	21.41	4.28	20	108
Ex. 1b	1.0	40.0	5.07	23.40	5.36	23	109
Ex. 7	0.5	40.2	5.00	20.30	3.81	19	96
Ex. 7	1.0	39.9	4.97	21.55	4.85	23	99
Ex. 8	0.5	40.9	5.08	19.56	3.79	19	96
Ex. 8	1.0	41.0	5.15	22.34	5.01	22	102
Comp. Ex. 4	0.5	39.9	4.94	20.05	4.32	22	-----
Comp. Ex. 4	1.0	40.3	5.05	22.03	5.16	23	-----
Ex. 16	0.5	40.3	4.91	20.15	4.31	21	100
Ex. 16	1.0	40.3	4.89	22.43	5.20	23	101
Comp. Ex. 5	0.5	40.4	4.90	19.60	3.18	16	-----
Comp. Ex. 5	1.0	40.8	4.93	19.80	4.04	20	-----
Ex. 21	0.5	38.8	4.77	20.21	3.99	20	126
Ex. 21	1.0	40.2	4.92	23.08	5.40	23	134

Footnotes for Table 7 and Table 8:

- (1) Wet and dry tensiles were linearly normalized to a basis weight of 40 lbs/3000 sq. ft.
 (2) Wet strength of paper made with treated resin expressed as a percentage of the wet strength of paper made with untreated resin at the same % of resin added.

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TABLE 8
Handsheet Evaluation of Base Treated Resin (Paper was Cured at 80°C for 30 min)

Example	% Added	Basis Wt. (lbs/3000 sq. ft.)	Caliper (mils)	Dry ⁽¹⁾ Tensile (lbs/in)	Wet ⁽¹⁾ Tensile (lbs/in)	% Wet/Dry	Wet Strength Percent ⁽²⁾
Blank	0.0	40.6	4.83	16.06	0.52	3	-----
Comp. Ex. 1	0.5	40.2	4.96	20.80	4.17	20	-----
Comp. Ex. 1	1.0	39.4	5.02	21.12	5.34	25	-----
Ex. 1	0.5	40.1	5.03	20.55	4.50	22	108
Ex. 1	1.0	39.1	4.93	21.28	5.49	26	103
Ex. 1b	0.5	40.2	5.06	21.89	4.52	21	108
Ex. 1b	1.0	40.2	5.04	23.88	5.66	24	106
Ex. 7	0.5	40.6	4.97	20.89	4.23	20	101
Ex. 7	1.0	39.8	4.98	22.21	5.17	23	97
Ex. 8	0.5	40.4	4.93	21.19	4.36	21	104
Ex. 8	1.0	40.8	5.00	21.96	5.23	24	98
Comp. Ex. 4	0.5	39.6	4.93	21.92	5.05	23	-----
Comp. Ex. 4	1.0	40.2	4.93	21.59	5.68	26	-----
Ex. 16	0.5	40.7	4.92	21.13	4.51	21	89
Ex. 16	1.0	40.8	4.95	20.78	5.52	27	97
Comp. Ex. 5	0.5	41.0	4.87	20.00	3.47	17	-----
Comp. Ex. 5	1.0	40.8	4.99	20.59	4.41	21	-----
Ex. 21	0.5	39.4	4.82	20.51	4.19	20	121
Ex. 21	1.0	40.2	4.92	22.09	5.59	25	127

TABLE 9

GC Analysis of Base Treated Wet-Strength Resins for Epichlorohydrin By-products

Example	Treatment Conditions	Mmole NaOH/g resin (dry basis)	epi	1,3-DCP (ppm) ⁽²⁾	2,3-DCP (ppm) ⁽³⁾	3-CPD (ppm) ⁽⁴⁾
Comp. Ex. 2	Untreated	None	< 1	< 1	1	57
Ex. 10	55°C for 5 min	2.8	< 1	< 1	< 1	6
Ex. 11	40°C for 5 min	2.8	< 1	< 1	1	51
Comp. Ex. 7	Untreated	None	< 0.1	< 0.1	0.7	2.5
Ex. 29	55°C for 5 min	2.8	< 0.1	< 0.1	0.5	0.5
Comp. Ex. 3	Untreated	None	< 1	178	8	188
Ex. 13	55 C for 5 min	2.8	108	< 1	< 1	10
Comp. Ex. 4	Untreated	None	< 10	800	< 10	190
Ex. 19	25°C for 5 min	2.0	440	45	< 1	324
Ex. 18	55°C for 5 min	2.0	439	14	< 1	163
Comp. Ex. 5	untreated	None	< 1	896	< 1	528
Ex. 22	55°C for 5 min	4.3	479	23	1	132
Comp. Ex. 6	untreated	None	< 10	1000	< 10	175
Ex. 28	25°C for 5 min	4.3	450	53	4	144
Ex. 25	55°C for 5 min	4.3	193	8	4	53

(1) epi = epichlorohydrin, ppm = parts per million in the resin (wet basis). The data for the base treated resins were corrected to a solids equal to the corresponding untreated resin.

(2) 1,3-DCP = 1,3-dichloropropanol, ppm = parts per million in the resin (wet basis). The data for the base treated resins were corrected to a solids equal to the corresponding untreated resin.

(3) 2,3-DCP = 2,3-dichloropropanol, ppm = parts per million in the resin (wet basis). The data for the base treated resins were corrected to a solids equal to the corresponding untreated resin.

(4) 3-CPD = 3-chloropropanediol, ppm = parts per million in the resin (wet basis). The data for the base treated resins were corrected to a solids equal to the corresponding untreated resin.

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Claims:

1. A process for reducing the AOX content of a starting water-soluble wet-strength resin comprising azetidinium ions and tertiary aminohalohydrin, comprising treating said resin in aqueous solution with base to form treated resin, wherein at least about 20% of the tertiary aminohalohydrin present in the starting resin is converted into epoxide, the level of azetidinium ion is substantially unchanged, and the effectiveness of the treated resin in imparting wet strength is at least about as great as that of said starting wet-strength resin.
2. The process of claim 1 wherein the starting water-soluble wet-strength resin is selected from the group consisting of polyaminopolyamide-epichlorohydrin resins and polyamine-epichlorohydrin resins and mixtures thereof.
3. The process of claim 1 wherein the base is selected from the group consisting of alkali metal hydroxides, carbonates and bicarbonates, alkaline earth metal hydroxides, trialkylamines and tetra alkylammonium hydroxides.
4. The process of claim 1 wherein the starting water-soluble wet-strength resin additionally comprises aminohalohydrin selected from the group consisting of secondary aminohalohydrin and quaternary ammonium halohydrin.
5. The process of claim 1 wherein up to about 100% of the aminohalohydrin present in the starting resin is converted into epoxide.

30

5 6. The process of claim 1 wherein the concentration of starting water-soluble wet-strength resin is at least about 1%.

7. The process of claim 1 wherein the concentration of starting water-soluble wet-strength resin is up to about 40%.

10

8. The process of claim 1 wherein the amount of base is at least about 0.5 millimoles per gram of starting resin on a dry basis.

9. The process of claim 1 wherein the amount of base is up to about 10 millimoles per gram of starting resin on a dry basis.

15

10. The process of claim 1 wherein the temperature is up to about 100°C.

20 11. The process of claim 1 wherein the starting water-soluble wet-strength resin is treated with base for at least about 1 minute.

12. The process of claim 1 wherein the starting water-soluble wet-strength resin is treated with base for up to about 24 hours.

25

13. The process of claim 2 wherein the base is selected from the group consisting of alkali metal hydroxides, carbonates and bicarbonates, alkaline earth metal hydroxides, trialkylamines and tetra alkylammonium hydroxides, up to about 100% of the tertiary amino halohydrin present in the starting wresin is converted into epoxide, the concentration of starting water-soluble resin is from about 1% to about 40%, the amount of base is from about 0.5 to about 10 millimoles per gram of starting resin on a dry basis, the temperature is up to about 100°C and the starting water-soluble wet-strength

30

5 resin is treated with base for a period of time from about 1 minute to about 24 hours.

14. The process of claim 13 wherein (a) the polyaminopolyamide-epichlorohydrin resin comprises the reaction product of epichlorohydrin and polyamide derived from polyalkylene polyamine and dibasic carboxylic acid or ester containing from about 3 to 10 carbon atoms, (b)
10 the polyamine-epichlorohydrin resin comprises the reaction product of epichlorohydrin and polyalkylene polyamine; and wherein the polyalkylene polyamine is selected from the group consisting of polyethylene polyamines, polypropylene polyamines, polybutylene polyamines, polypentylene polyamines, polyhexylene polyamines and mixtures thereof.

15 15. The process of claim 13 wherein the base is selected from the group consisting of sodium carbonate, potassium carbonate, sodium hydroxide and potassium hydroxide.

16. The process of claim 13 wherein the tertiary aminohalohydrin is tertiary aminochlorohydrin.
20

17. The process of claim 13 wherein at least about 50% of the tertiary aminohalohydrin present in the starting resin is converted into epoxide.

18. The process of claim 13 wherein the concentration of starting water-soluble wet-strength
25 resin is at least about 2%.

19. The process of claim 13 wherein the concentration of starting water-soluble wet-strength resin is up to about 25%.
30

5 20. The process of claim 13 wherein the amount of base is at least about 1.5 millimoles per gram of starting resin on a dry basis.

21. The process of claim 13 wherein the amount of base is up to about 8 millimoles per gram of starting resin on a dry basis.

10

22. The process of claim 13 wherein the temperature is at least about 20°C.

23. The process of claim 13 wherein the temperature is up to about 80°C.

15 24. The process of claim 13 wherein the starting water-soluble wet-strength resin is treated with base for at least about 3 minutes.

25. The process of claim 13 wherein the starting water-soluble wet-strength resin is treated with base for up to about 4 hours.

20

26. The process of claim 14 wherein the base is selected from the group consisting of sodium carbonate, potassium carbonate, sodium hydroxide and potassium hydroxide, the tertiary aminohalohydrin is tertiary aminochlorohydrin, from about 50 to about 100% of the tertiary aminohalohydrin present in the starting resin is converted into epoxide, the concentration of the starting water-soluble wet-strength resin is from about 2% to about 25%, the amount of base is from about 1.5 to about 8 millimoles per gram of starting resin on a dry basis, the temperature is from about 20°C to about 80°C and the starting water-soluble wet-strength resin is treated with base for a period of from about 3 minutes to about 4 hours.

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5 27. The process of claim 26 wherein (a) the polyaminopolyamide-epichlorohydrin resin comprises the reaction product of epichlorohydrin and polyamide derived from polyalkylene polyamine selected from the group consisting of diethylenetriamine, triethylenetetramine, tetraethylenepentamine and mixtures thereof and dibasic carboxylic acid or ester selected from the group consisting of glutaric acid, adipic acid, their esters and mixtures thereof and (b) the
10 polyamine-epichlorohydrin resin comprises the reaction product of epichlorohydrin and polyalkylene polyamine selected from the group consisting of hexamethylenediamine, bishexamethylenetriamine and mixtures thereof.

15 28. The process of claim 26 wherein the base is selected from the group consisting of sodium hydroxide and potassium hydroxide.

29. The process of claim 26 wherein at least about 90% of the tertiary aminochlorohydrin present in the starting resin is converted into epoxide.

20 30. The process of claim 26 wherein the concentration of the starting water-soluble wet-strength resin is at least about 5%.

31. The process of claim 26 wherein the concentration of the starting water-soluble wet-strength resin is up to about 15%.

25 32. The process of claim 26 wherein the temperature is at least about 40°C.

- 5 33. The process of claim 26 wherein the temperature is up to about 60° C.
34. The process of claim 26 wherein the starting water-soluble wet-strength resin is treated with base for at least about 5 minutes.
- 10 35. The process of claim 27 wherein the starting water-soluble wet-strength resin is treated with base for up to about 1 hour.
36. The process of claim 27 wherein the base is selected from the group consisting of sodium hydroxide and potassium hydroxide, from about 90 to about 100% of the tertiary aminohalohydrin present in the starting resin is converted into epoxide, the concentration of
15 starting water-soluble wet-strength resin is from about 5% to about 15%, the temperature is from about 40°C to about 60°C and the starting water-soluble wet-strength resin is treated with base for a period of from about 5 minutes to about 1 hour.
- 20 37. The water-soluble wet-strength resin prepared by the process of claim 1.
38. The water-soluble wet-strength resin prepared by the process of claim 13.
39. The water-soluble wet-strength resin prepared by the process of claim 26.
- 25 40. The water-soluble wet-strength resin prepared by the process of claim 36.

- 5 41. A process for preparing paper comprising:
- (a) providing aqueous pulp slurry
 - (b) adding to the aqueous pulp slurry the water-soluble wet- strength resin of claim 37
 - (c) sheeting and drying the aqueous pulp slurry to produce paper.
- 10
42. A process for preparing paper comprising:
- (a) providing aqueous pulp slurry
 - (b) adding to the aqueous pulp slurry the water-soluble wet- strength resin of claim 38
 - (c) sheeting and drying the aqueous pulp slurry to produce paper.
- 15
43. A process for preparing paper comprising:
- (a) providing aqueous pulp slurry
 - (b) adding to the aqueous pulp slurry the water-soluble wet-strength resin of claim 39
 - (c) sheeting and drying the aqueous pulp slurry to produce paper.
- 20
44. A process for preparing paper comprising:
- (a) providing aqueous pulp slurry
 - (b) adding to the aqueous pulp slurry the water-soluble wet-strength resin of claim 40
 - (c) sheeting and drying the aqueous pulp slurry to produce paper.
- 25
45. Paper prepared by the process of claim 41.
- 30
46. Paper prepared by the process of claim 42.
47. Paper prepared by the process of claim 43.
- 35

5 48. Paper prepared by the process of claim 44.

 49. A process comprising treating a starting water-soluble wet-strength resin comprising azetidinium ions and tertiary aminohalohydrin in aqueous solution with base to form treated resin, wherein the starting water-soluble wet-strength resin is selected from the group consisting of polyaminopolyamide-epichlorohydrin resins and polyamine-epichlorohydrin resins and mixtures thereof and the base is selected from the group consisting of alkali metal hydroxides, carbonates and bicarbonates, alkaline earth metal hydroxides, trialkylamines, tetraalkylammonium hydroxides, ammonia, organic amines, alkali metal sulfides, alkaline earth sulfides, alkali metal alkoxides and alkaline earth alkoxides.

15 50. The process of claim 49 wherein up to about 100% of the tertiary aminohalohydrin present in the starting resin is converted into epoxide, the concentration of starting water-soluble resin is from about 1% to about 40%, the amount of base is from about 0.5 to about 10 millimoles per gram of starting resin on a dry basis, the temperature is up to about 100°C and the starting water-soluble wet-strength resin is treated with base for a period of time of from about 1 minute to about 24 hours.

 51. A process for reducing the AOX content of a composition comprising halohydrin functionality and azetidinium ions comprising treating the composition with base.

25 52. A process for reducing the AOX content of a composition comprising tertiary amines with a halohydrin functionality comprising treating the composition with base.

 53. A process for reducing the AOX content of a composition comprising halohydrin functionality comprising treating the composition with base at a temperature of at least about 40°C.

- 5 54. A process for reducing the AOX content of a composition comprising halohydrin functionality comprising treating the composition with base at a temperature of up to about 100°C.
55. A process for reducing the AOX content of a composition comprising halohydrin
10 functionality comprising treating the composition with base at a solids content of at least about 6% based upon the weight of the composition.
56. A process for reducing the AOX content of a composition comprising halohydrin functionality comprising treating the composition with base at a solids content of up to about
15 40% based upon the weight of the composition.
57. The process of claim 51 wherein the pH is at least about 8.
58. The process of claim 51 wherein the pH is up to about 13.
20
59. A process for reducing the AOX content of a composition comprising halohydrin functionality comprising treating the composition with base wherein the AOX content is reduced to less than about 50% of the AOX content in the untreated composition on an equal solids level basis.
25
60. A process for reducing the AOX content of a composition comprising quaternary amines with a halohydrin functionality comprising treating the composition with base at a temperature of from about 40°C to about 100°C.
- 30 61. A process for reducing the AOX content of a composition comprising quaternary amines with a halohydrin functionality comprising treating the composition with base at a solids content of from about 6 to about 40% based upon the weight of the composition.

5 62. The process of claim 51 wherein the composition comprises an aqueous solution comprising wet strength agent.

 63. The process of claim 52 wherein the composition comprises an aqueous solution comprising wet strength agent.
10

 64. The process of claim 53 wherein the composition comprises an aqueous solution comprising wet strength agent.

 65. The process of claim 54 wherein the composition comprises an aqueous solution comprising wet strength agent.
15

 66. The process of claim 55 wherein the composition comprises an aqueous solution comprising wet strength agent.

20 67. The process of claim 56 wherein the composition comprises an aqueous solution comprising wet strength agent.

 68. The process of claim 57 wherein the pH is at least about 9.

25 69. The process of claim 58 wherein the pH is up to about 12.5.

 70. The process of claim 59 wherein the composition comprises an aqueous solution comprising wet strength agent.

30 71. The process of claim 60 wherein the composition comprises an aqueous solution comprising wet strength agent.

 72. The process of claim 61 wherein the composition comprises an aqueous solution comprising wet strength agent.
35

 73. The process of claim 62 wherein the solids of the aqueous solution of wet strength agent are treated with base before the wet strength agent is added to aqueous paper pulp.

5 74. The process of claim 63 wherein the solids of the aqueous solution of wet strength agent are treated with base before the wet strength agent is added to aqueous paper pulp.

 75. The process of claim 64 wherein the solids of the aqueous solution of wet strength agent are treated with base before the wet strength agent is added to aqueous paper pulp.

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 76. The process of claim 65 wherein the solids of the aqueous solution of wet strength agent are treated with base before the wet strength agent is added to aqueous paper.

 77. The process of claim 66 wherein the solids of the aqueous solution of wet strength agent are treated with base before the wet strength agent is added to aqueous paper pulp.

15

 78. The process of claim 67 wherein the solids of the aqueous solution of wet strength agent are treated with base before the wet strength agent is added to aqueous paper pulp.

20

 79. The process of claim 68 wherein the pH is at least about 10.

 80. The process of claim 69 wherein the pH is up to about 12.

 81. The process of claim 70 wherein the solids of the aqueous solution of wet strength agent are treated with base before the wet strength agent is added to aqueous paper pulp.

25

 82. The process of claim 71 wherein the solids of the aqueous solution of wet strength agent are treated with base before the wet strength agent is added to aqueous paper pulp.

30

5 83. The process of claim 72 wherein the solids of the aqueous solution of wet strength agent are treated with base before the wet strength agent is added to aqueous paper pulp.

 84. The process of claim 73 comprising adding the treated wet strength agent to aqueous paper pulp within from about 1 minute to about 24 hours after base treatment reached
10 the desired level of AOX content reduction.

 85. The process of claim 74 comprising adding the treated wet strength agent to aqueous paper pulp within from about 1 minute to about 24 hours after base treatment reached
15 the desired level of AOX content reduction.

 86. The process of claim 75 comprising adding the treated wet strength agent to aqueous paper pulp within from about 1 minute to about 24 hours after base treatment reached
20 the desired level of AOX content reduction.

 87. The process of claim 76 comprising adding the treated wet strength agent to aqueous paper pulp within from about 1 minute to about 24 hours after base treatment reached
25 the desired level of AOX content reduction.

 88. The process of claim 77 comprising adding the treated wet strength agent to aqueous paper pulp within from about 1 minute to about 24 hours after base treatment reached
30 the desired level of AOX content reduction.

 89. The process of claim 78 comprising adding the treated wet strength agent to aqueous paper pulp within from about 1 minute to about 24 hours after base treatment reached
30 the desired level of AOX content reduction.

5 90. The process of claim 79 wherein the pH is at least about 10.5.

 91. The process of claim 80 wherein the pH is up to about 11.5.

 92. The process of claim 81 comprising adding the treated wet strength agent to
10 aqueous paper pulp within from about 1 minute to about 24 hours after base treatment reached
the desired level of AOX content reduction.

 93. The process of claim 82 comprising adding the treated wet strength agent to
aqueous paper pulp within from about 1 minute to about 24 hours after base treatment reached
15 the desired level of AOX content reduction.

 94. The process of claim 83 comprising adding the treated wet strength agent to
aqueous paper pulp within from about 1 minute to about 24 hours after base treatment reached
the desired level of AOX content reduction.

20 95. The process of claim 51 wherein up to 100% of the halohydrin functionality is
converted into epoxide.

 96. The process of claim 52 wherein up to 100% of the halohydrin functionality is
25 converted into epoxide.

 97. The process of claim 53 wherein up to 100% of the halohydrin functionality is
converted into epoxide.

30 98. The process of claim 54 wherein up to 100% of the halohydrin functionality is
converted into epoxide.

 99. The process of claim 55 wherein up to 100% of the halohydrin functionality is
converted into epoxide.

35

5 100. The process of claim 56 wherein up to 100% of the halohydrin functionality is converted into epoxide.

 101. The process of claim 53 wherein the temperature is at least about 45°C.

10 102. The process of claim 54 wherein the temperature is up to about 80°C.

 103. The process of claim 59 wherein up to 100% of the halohydrin functionality is converted into epoxide.

15 104. The process of claim 60 wherein up to 100% of the halohydrin functionality is converted into epoxide.

 105. The process of claim 61 wherein up to 100% of the halohydrin functionality is converted into epoxide.

20 106. The process of claim 51 wherein the level of azetidinium ion is substantially unchanged.

 107. The process of claim 52 wherein the level of azetidinium ion is substantially
25 unchanged.

 108. The process of claim 53 wherein the level of azetidinium ion is substantially unchanged.

30 109. The process of claim 54 wherein the level of azetidinium ion is substantially unchanged.

 110. The process of claim 55 wherein the level of azetidinium ion is substantially
35 unchanged.

- 5 111. The process of claim 56 wherein the level of azetidinium ion is substantially unchanged.
112. The process of claim 55 wherein the solids content is at least about 8%.
- 10 113. The process of claim 56 wherein the solids content is up to about 25%.
114. The process of claim 59 wherein the level of azetidinium ion is substantially unchanged.
- 15 115. The process of claim 60 wherein the level of azetidinium ion is substantially unchanged.
116. The process of claim 61 wherein the level of azetidinium ion is substantially unchanged.
- 20 117. The process of claim 51 wherein the wet strength effectiveness of the composition is not substantially lowered.
118. The process of claim 52 wherein the wet strength effectiveness of the composition is not substantially lowered.
- 25 119. The process of claim 53 wherein the wet strength effectiveness of the composition is not substantially lowered.
120. The process of claim 54 wherein the wet strength effectiveness of the composition is not substantially lowered.
- 30 121. The process of claim 55 wherein the wet strength effectiveness of the composition is not substantially lowered.

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5 122. The process of claim 56 wherein the wet strength effectiveness of the composition is not substantially lowered.

 123. The process of claim 59 wherein the AOX content is reduced to less than about 25% of the AOX content in the untreated composition on an equal solids level basis.

10

 124. The process of claim 123 wherein the AOX content is reduced to less than about 10% of the AOX content in the untreated composition on an equal solids level basis.

15

 125. The process of claim 59 wherein the wet strength effectiveness of the composition is not substantially lowered.

 126. The process of claim 60 wherein the wet strength effectiveness of the composition is not substantially lowered.

20

 127. The process of claim 61 wherein the wet strength effectiveness of the composition is not substantially lowered.

25

 128. A process to prepare a polymer comprising azetidinium ion and aminoepoxide having reduced AOX content comprising treating a polymer comprising halohydrin functionality and azetidinium ions with base.

 129. The process of claim 128 wherein the polymer having reduced AOX content comprises a cross-linkable polymer.

30

 130. The process of claim 128 wherein the polymer having reduced AOX content comprises a water soluble polymer.

 131. The process of claim 128 wherein the polymer having reduced AOX content comprises a cross-linked polymer.

35

5 132. The process of claim 51 wherein the halohydrin functionality comprises tertiary aminohalohydrin.

133. The process of claim 101 wherein the temperature is at least about 50°C.

10 134. The process of claim 102 wherein the temperature is up to about 60°C.

135. The process of class 112 wherein the solids content is at least about 10%.

136. The process of claim 113 wherein the solids content is up to about 15%.

15

137. The process of claim 124 wherein the AOX content is reduced to less than about 5% of the AOX content in the untreated composition on an equal solids level basis.

20 138. The process of claim 137 wherein the AOX content is reduced to less than about 1% of the AOX content in the untreated composition on an equal solids level basis.

139. The process of claim 138 wherein the AOX content is reduced to less than about 0.5% of the AOX content in the untreated composition on an equal solids level basis.

25 140. The process of claim 51 wherein the base is selected from the group consisting of alkali metal hydroxides, carbonates and bicarbonates, alkaline earth metal hydroxides, trialkylamines, tetra alkylamonium hydroxides, ammonia, organic amines, alkali metal sulfides, alkaline earth sulfides, alkali metal alkoxides and alkaline earth alkoxides.

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5 141. The process of claim 140 wherein the base is selected from the group consisting of alkali metal hydroxides and alkali metal carbonates.

 142. The process of claim 141 wherein the base is selected from the group consisting of sodium hydroxide and potassium hydroxide.

INTERNATIONAL SEARCH REPORT

Int. l. Application No

PCT/US 98/27538

A. CLASSIFICATION OF SUBJECT MATTER

IPC 6 C08G73/02 D21H17/55 D21H21/20

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

IPC 6 C08G D21H

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	EP 0 776 923 A (AKZO NOBEL NV) 4 June 1997 see page 6, line 28 - line 32; claims 1-10 & WO 92 22601 A cited in the application ---	1-50, 128-131
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☒ Further documents are listed in the continuation of box C.

☒ Patent family members are listed in annex.

* Special categories of cited documents :

"A" document defining the general state of the art which is not considered to be of particular relevance

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"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone

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INTERNATIONAL SEARCH REPORT

In: International Application No

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C.(Continuation) DOCUMENTS CONSIDERED TO BE RELEVANT

Category	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	<p>EP 0 374 938 A (SUMITOMO CHEMICAL CO)</p> <p>27 June 1990</p> <p>see claims 1-4</p> <p>-----</p>	<p>1-50,</p> <p>128-131</p>

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Information on patent family members

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